EAST Search History

EAST Search History						ALS
Ref #	Hits	Search Query	DBs	Default Operat or	Plural s	Time Stamp
L1	479	((workpiece or semiconductor or substrate or wafer) near5 (wash or washed or washer or washing or clean or cleaner or cleaning or cleaned or decontaminat\$4) near5 (foam\$4 or froth\$4 or bubbles or sud\$4))	US-PGPU B; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2007/05/14 04:44
L2		((workpiece or semiconductor or substrate or wafer) near5 (wash or washed or washer or washing or clean or cleaner or cleaning or cleaned or decontaminat\$4) near5 (foam\$4 or froth\$4 or bubbles or sud\$4)) and ((foam\$4 or froth\$4 or bubbles or sud\$4) near6 ozon\$4)	US-PGPU B; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2007/05/14 04:49